

UFSD update

Test beam results

Sensor design

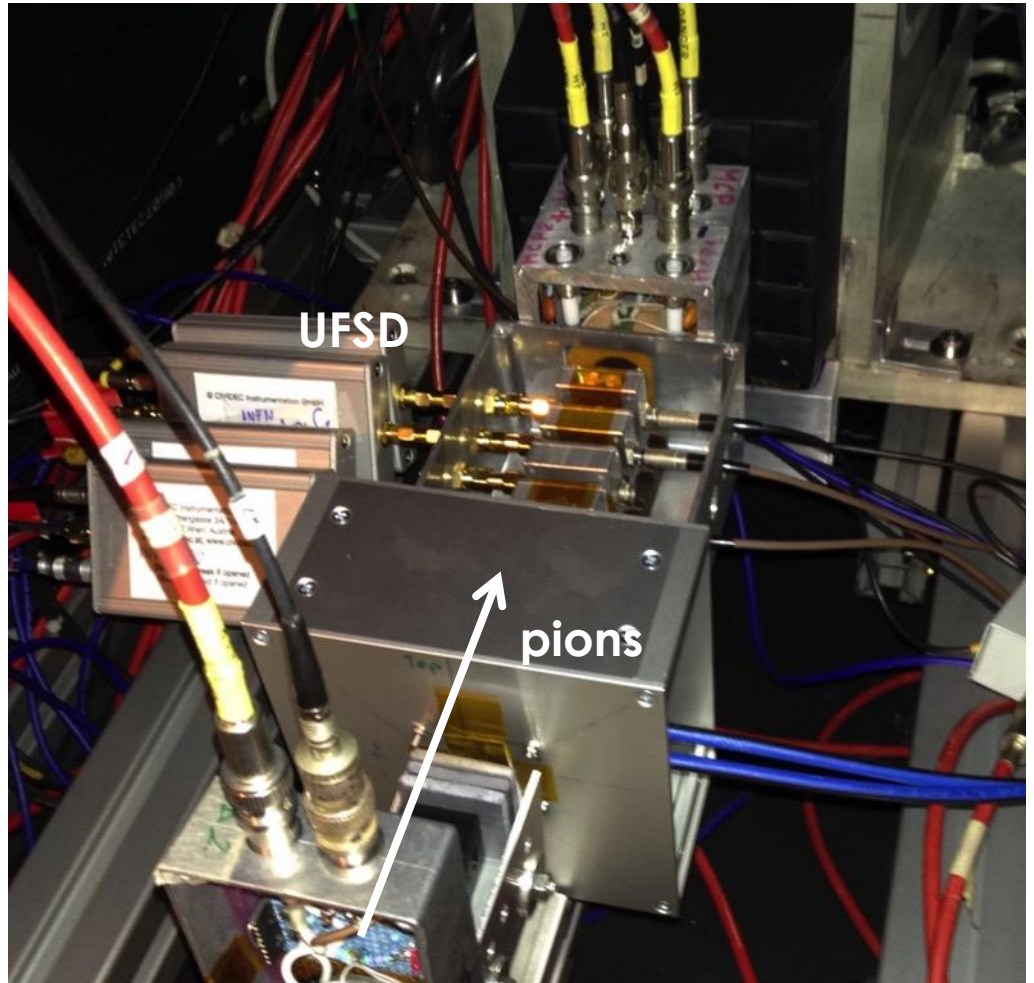
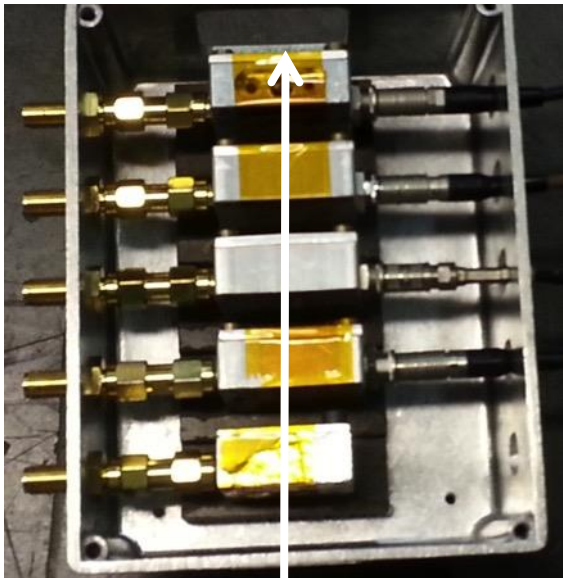
Board design

Timeline

INFN and Università di Torino, Università Piemonte Orientale

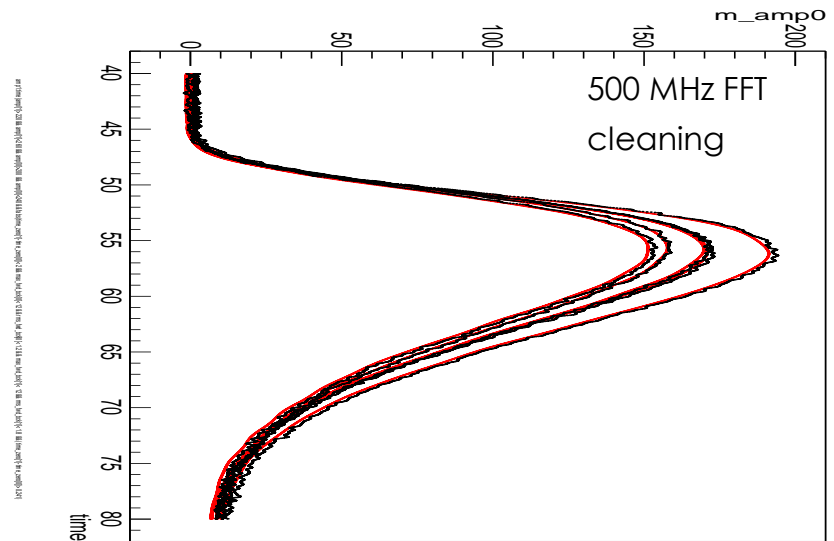
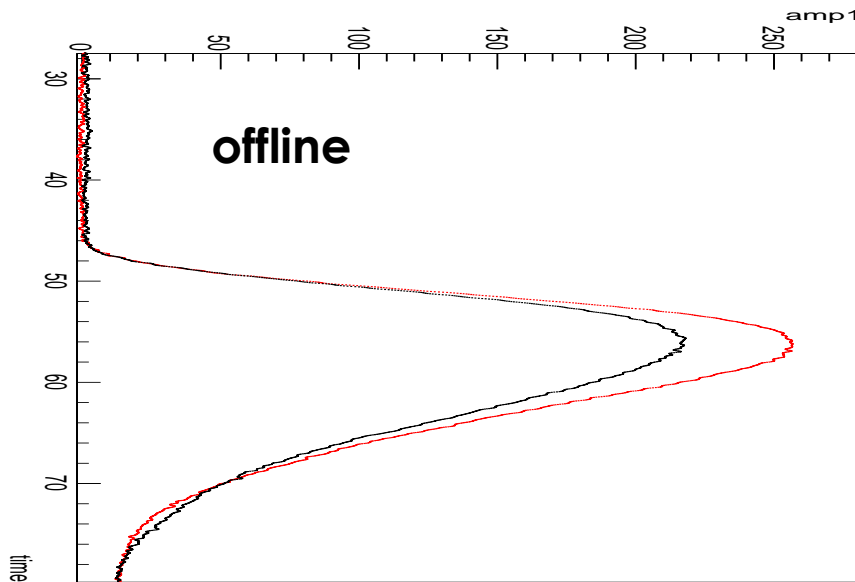
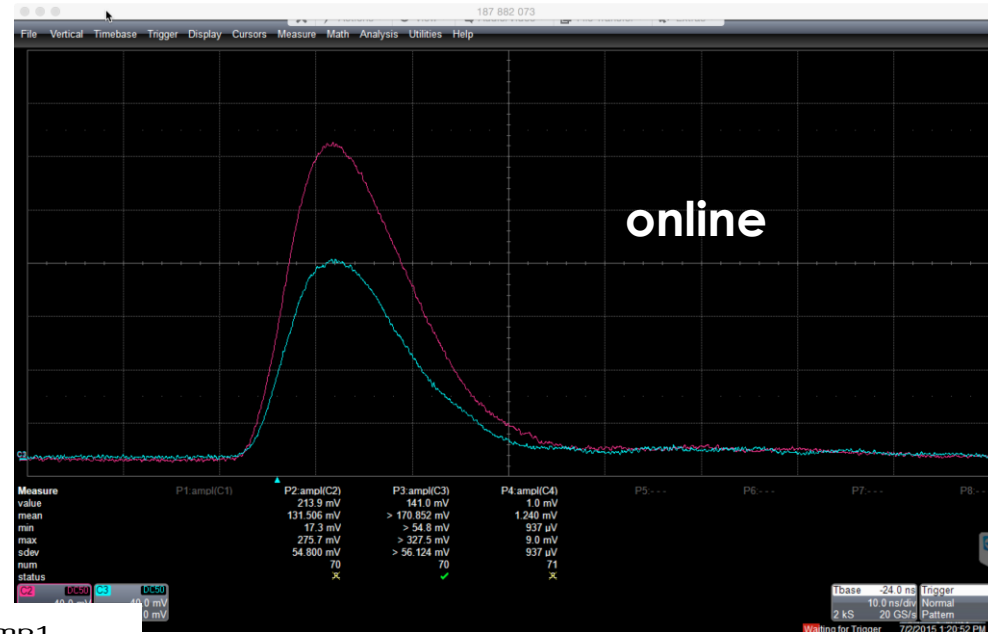
Testbeam Set-up

Testbeam part of the July
CMS HGC

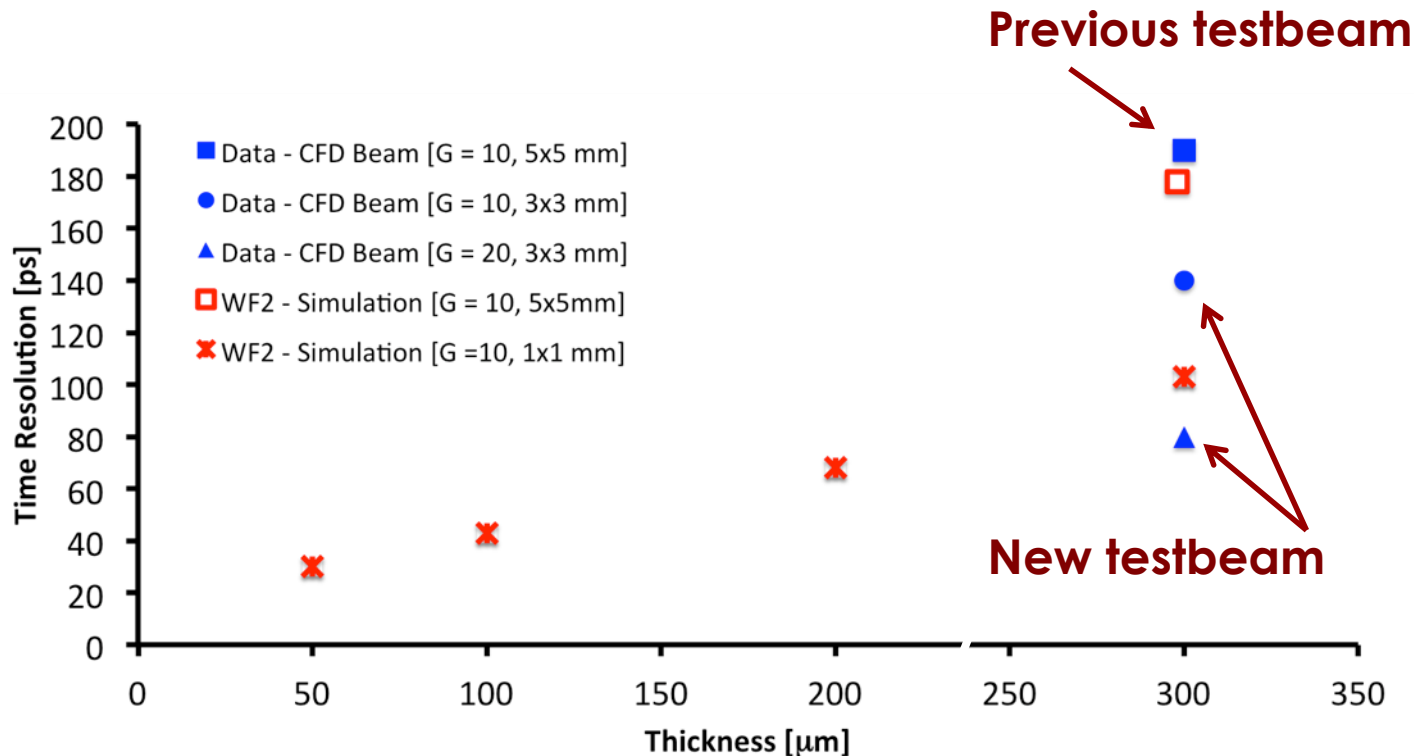


Testbeam: signal and noise

- Testbeam, very clean shape:
- 120 GeV muons
- Two UFSD, gain 10 and gain 20.
- Read-out with a CSA amplifier with a 4 ns integration time.
- Noise ~ 1 mV,
- Signal ~ 150 -200 mV
- Rise time 20-80% ~ 5 ns



Testbeam Results



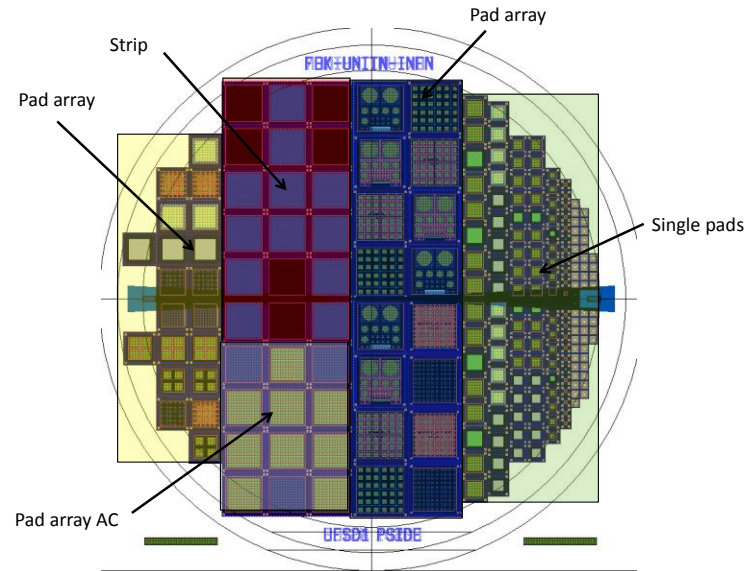
300 micron thick, ~ 4 pF sensor

Gain 10 → resolution ~ 145 ps

Gain 20 → resolution ~ 85 ps

New productions: winter 2015

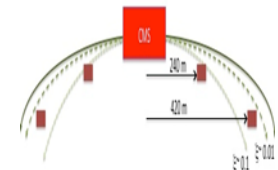
FBK: 300 micron, UFSD new production.
Gain foreseen ~ 10-20



CNM: 50 and 100 micron thick silicon,
with final PPS geometry → next pages

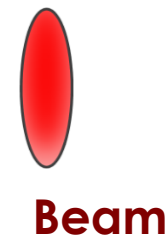
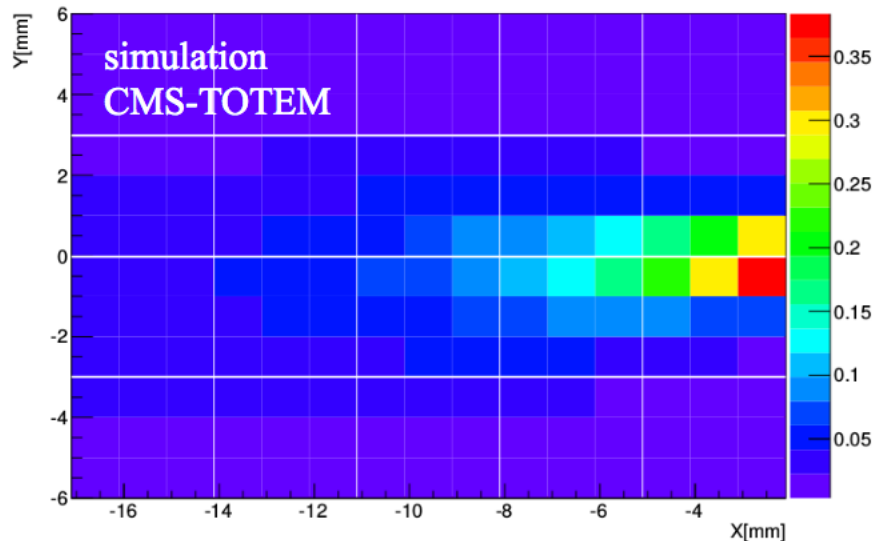


Possible Coverage



Detector occupancy per mm² at pile-up = 50

Use as reference the Quartic coverage



How large each pad can be?

1 mm² = 2 pF for 50 micron thick sensors

1 mm² = 1 pF for 100 micron thick sensors

Need to evaluate

- dV/dt vs area.
- How long each bond wire can be
- Electronic noise

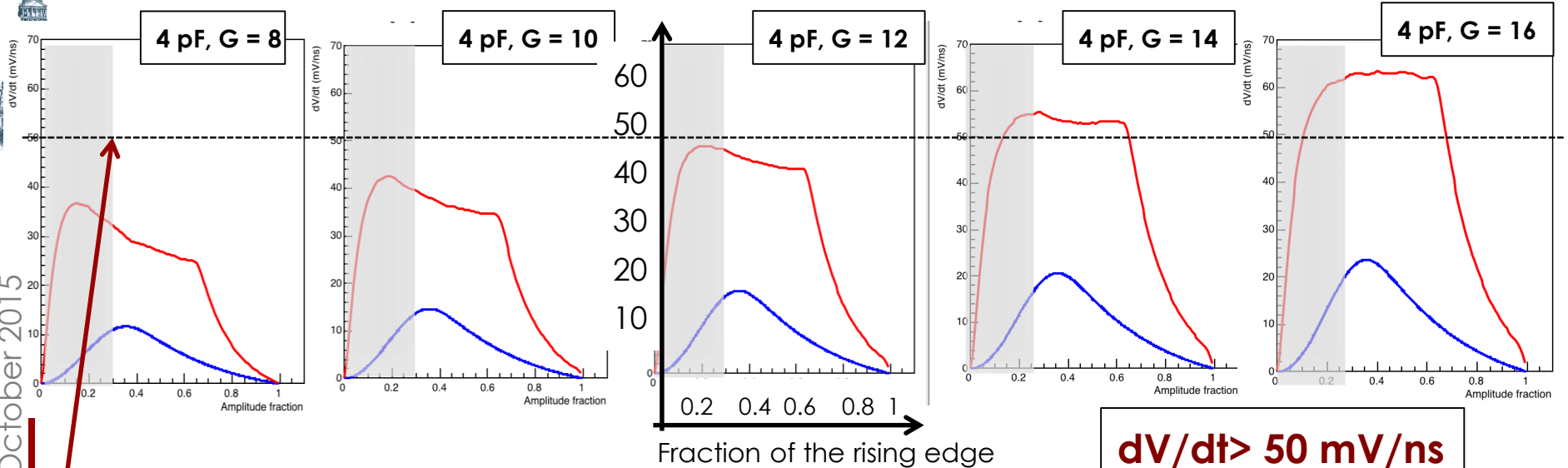
Set as goal 1 mV noise → dV/dt ~ 50 mV/ns to obtain 20 ps resolution



dV/dt vs Signal fraction for C = 4, 6 pF and gain = 8, 10, 12, 14, 16



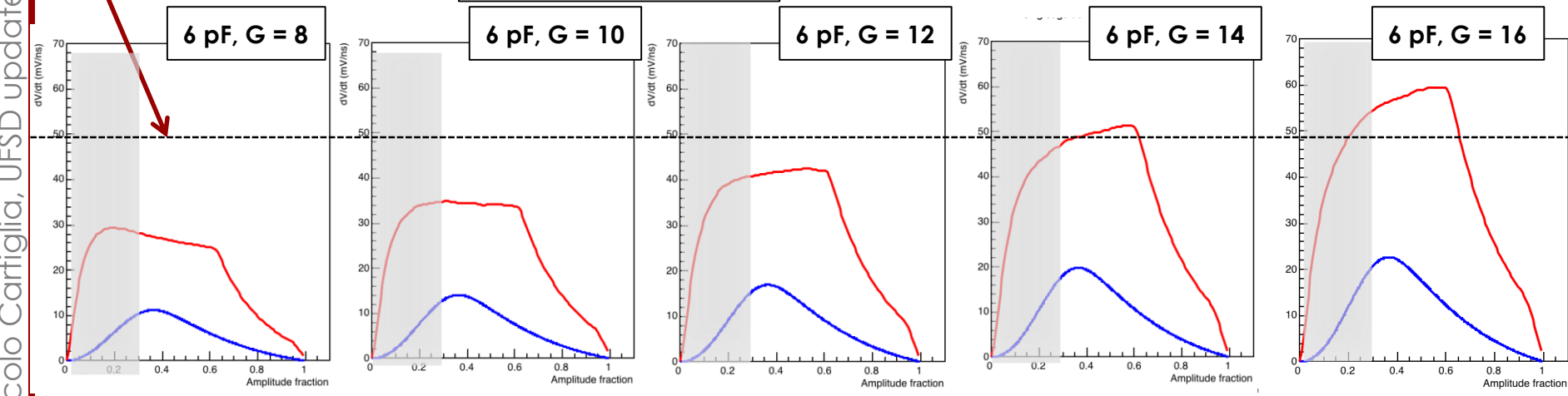
Nicolo Cartiglia, UFSd update, CT-PPS - October 2015

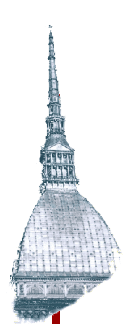


$dV/dt = 50 \text{ mV/ns}$

BB amplifier, 40 db,
R input = 50 Ohm,
Gain = 8 - 16

$dV/dt > 50 \text{ mV/ns}$
Gain = 14-16
C = 4-6 pF

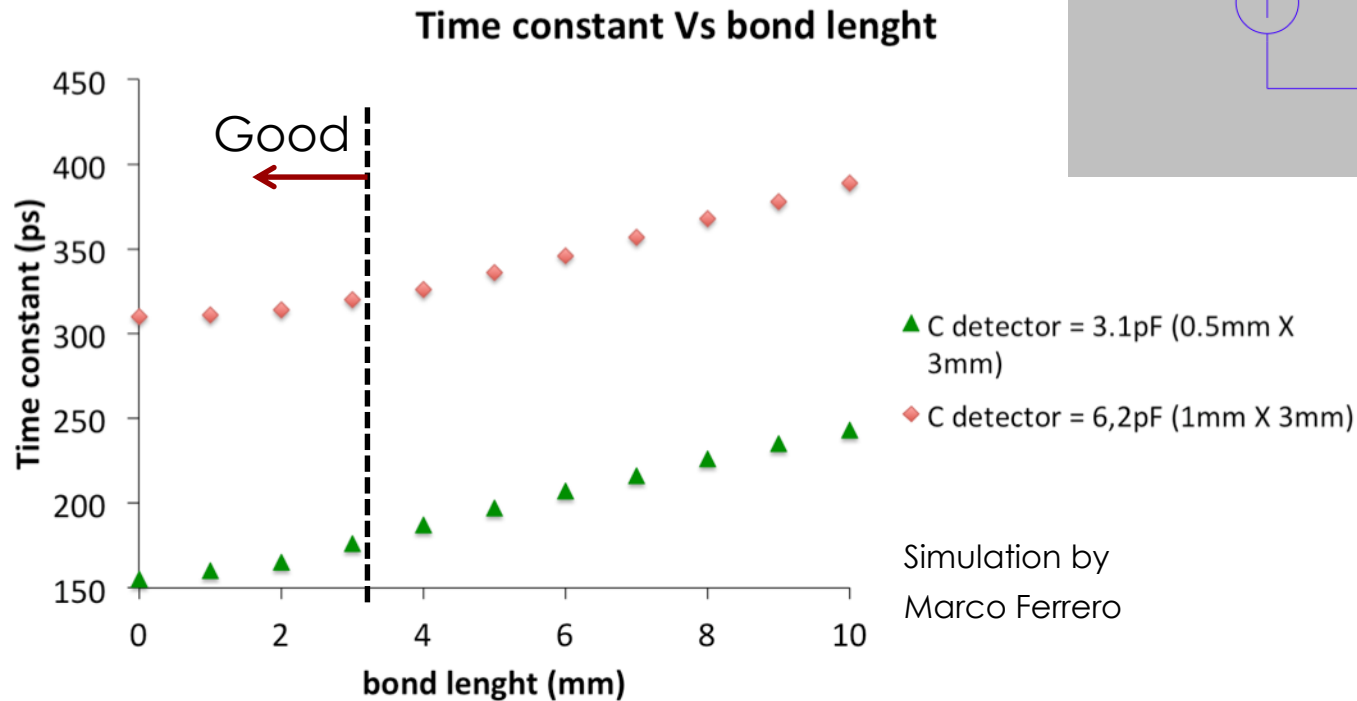
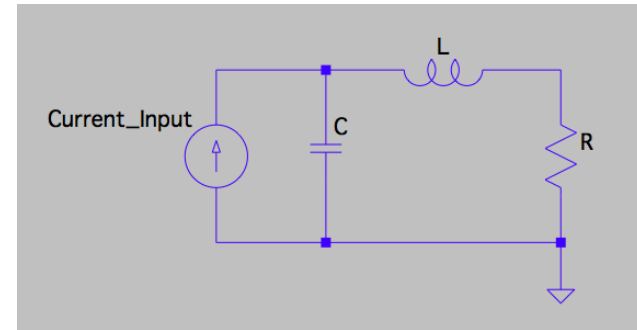




Bond wire

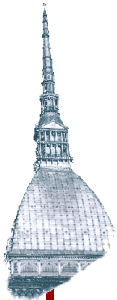
The geometry of the sensor has to take into account the bond-wire length

A bond wire act as an inductor of 0.8 nH/mm placed in between the detector capacitance C and the amplifier input resistance R

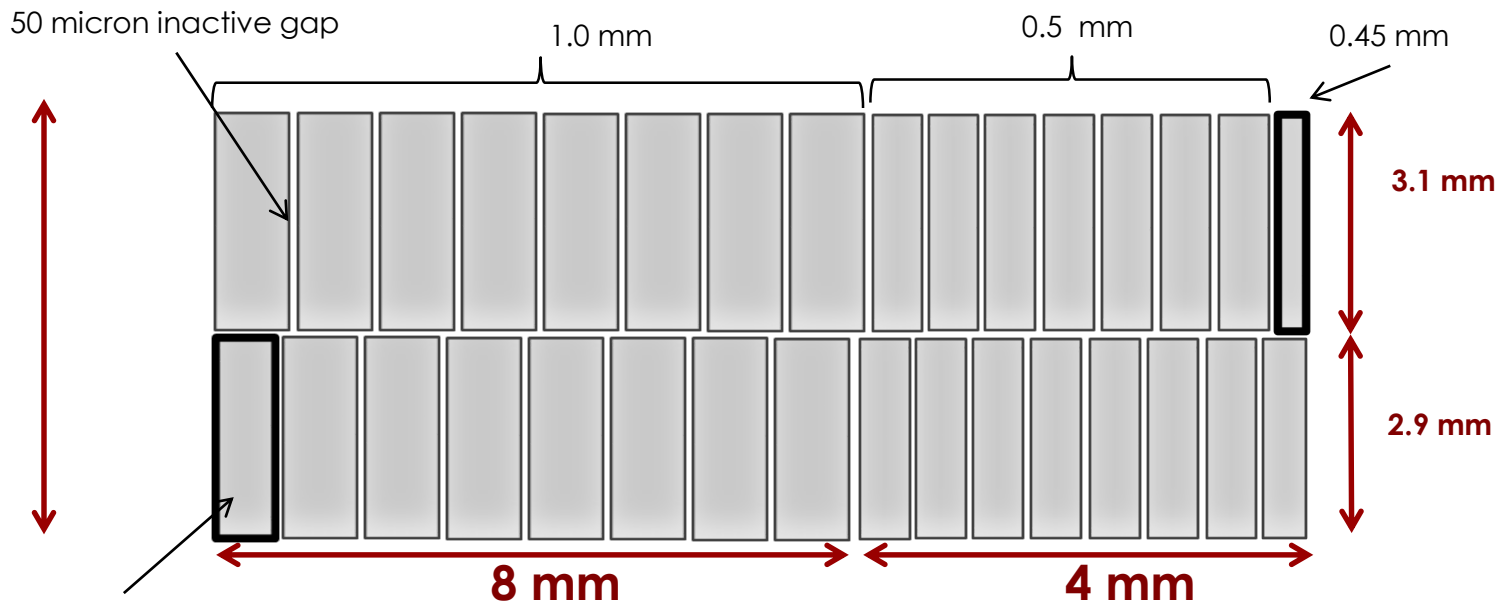


Simulation by
Marco Ferrero

CT-PPS proposed sensor geometry



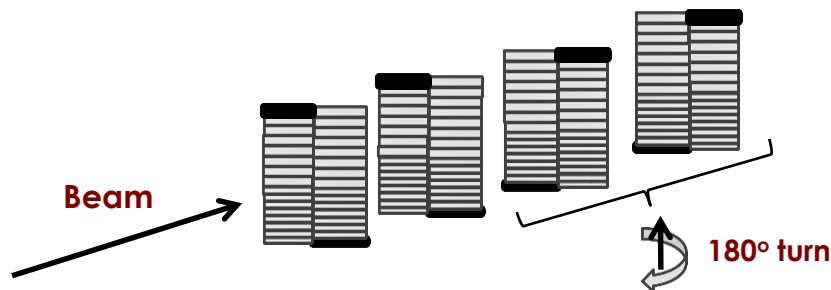
6 mm



16 Pixel $\sim 3 \text{ mm}^2$
Cap. Pixel $\sim 6 \text{ pF}$

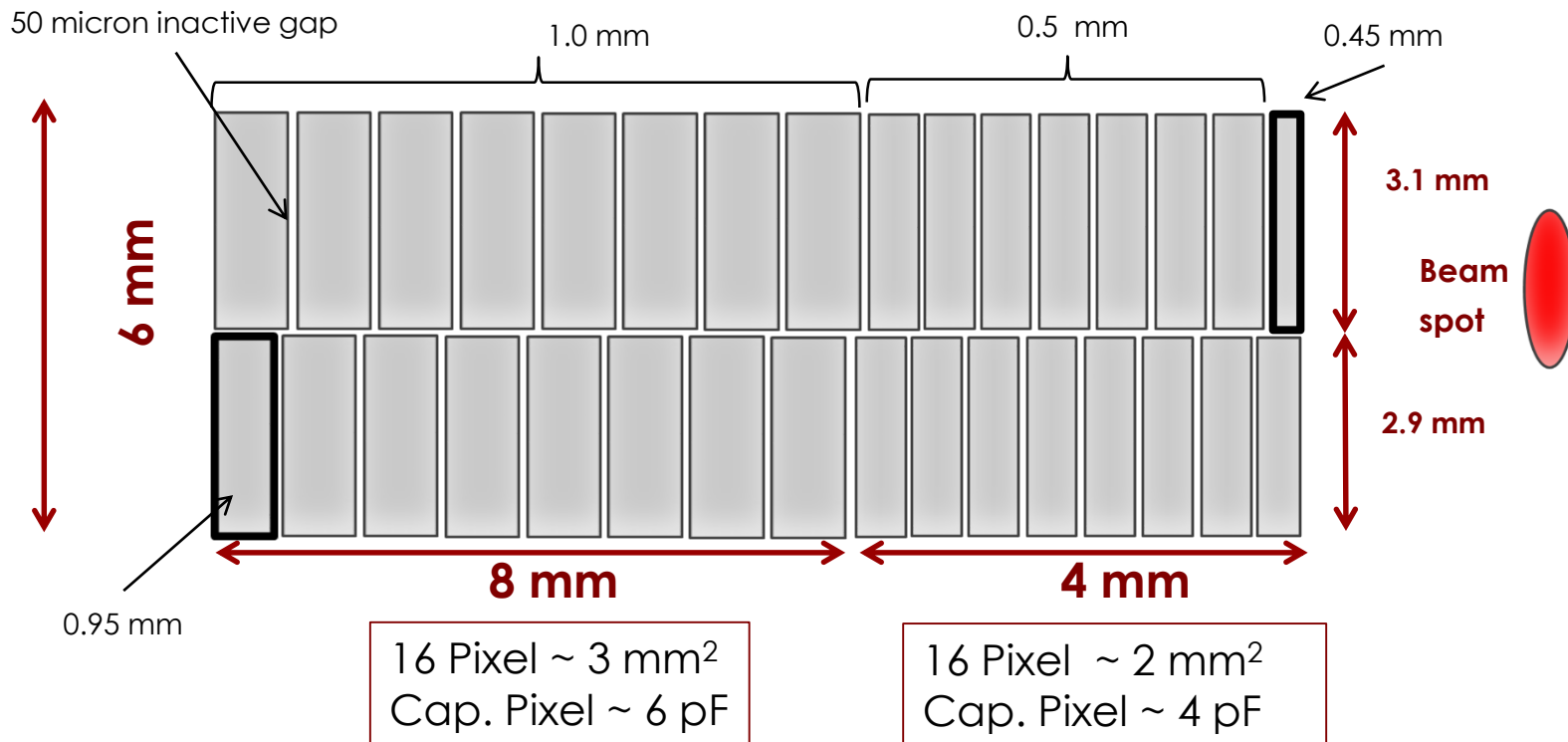
16 Pixel $\sim 2 \text{ mm}^2$
Cap. Pixel $\sim 4 \text{ pF}$

Asymmetric designed
Area = 12mmX6mm;
Thickness = 50 μm ;
of pixels = 32

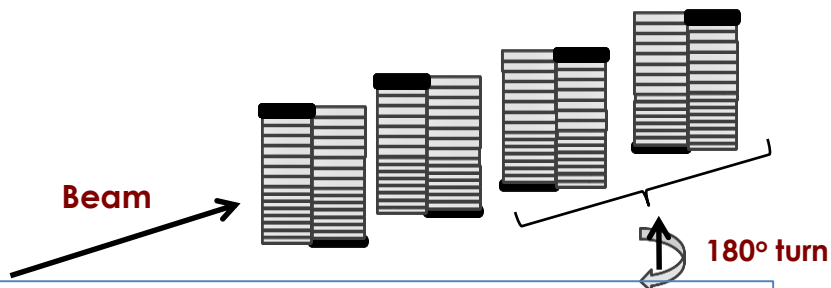


No cracks aligned: 2 (3) planes facing the beam, and 2 (3) turned by 180°

CT-PPS proposed sensor geometry



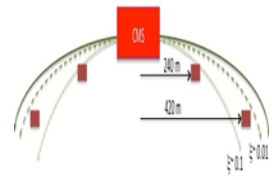
Asymmetric designed
Area = 12mmX6mm;
Thickness = 50 μ m;
of pixels = 32



No cracks aligned: 2 (3) planes facing the beam, and 2 (3) turned by 180°



UFSD expected time resolution

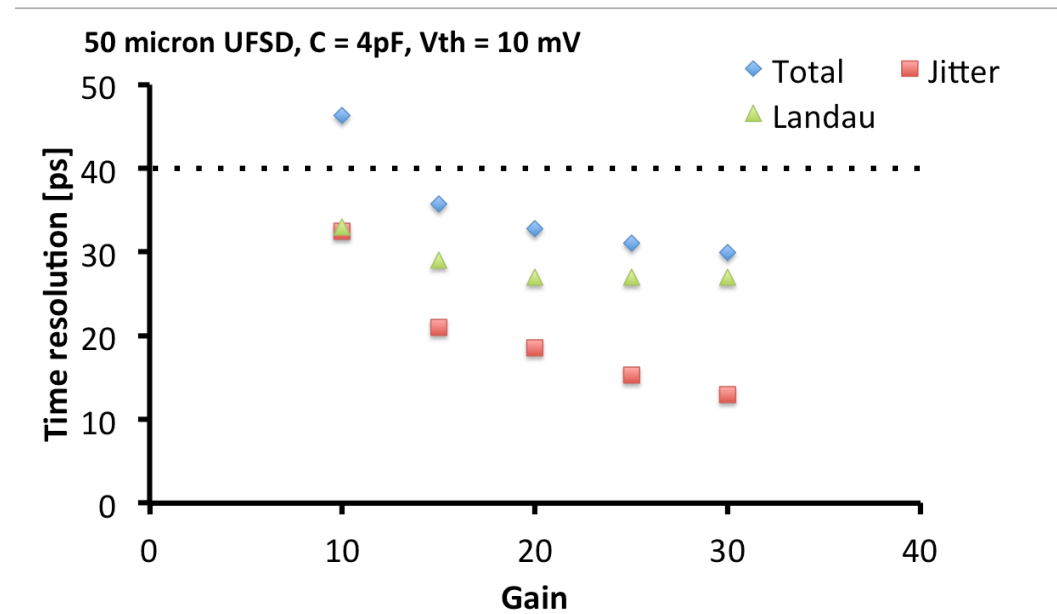


What resolution per plane can we expect?

There are 2 known main contributions:

Noise \rightarrow jitter (from current electronics and testbeam)

Landau fluctuations \rightarrow additional time spread (from simulation)



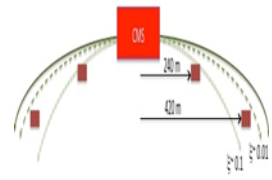
For gain $>\sim 15 \rightarrow \sigma < 40\text{ ps}$

Note we remain below 40 ps even assuming an un-accounted for additional time spread of 20 ps.



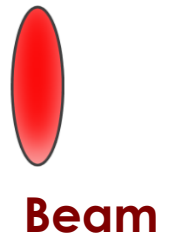
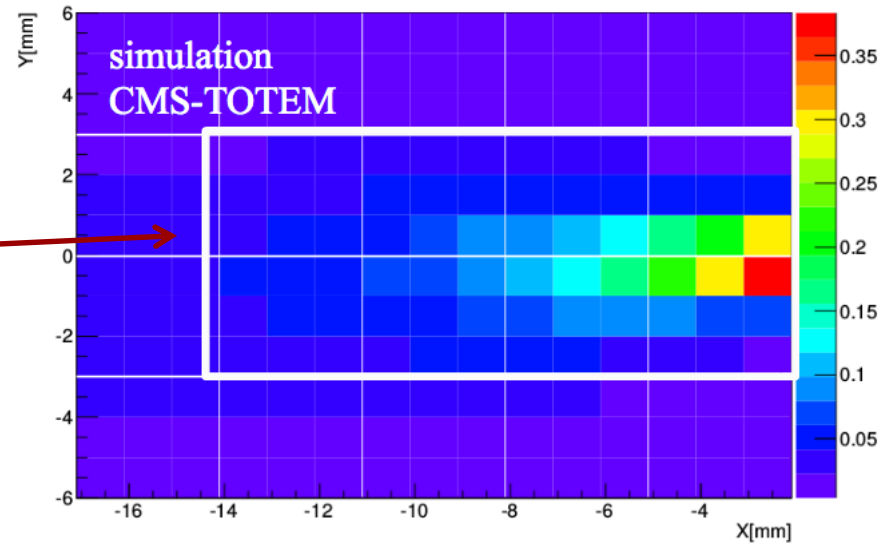


Comparison with Quartic



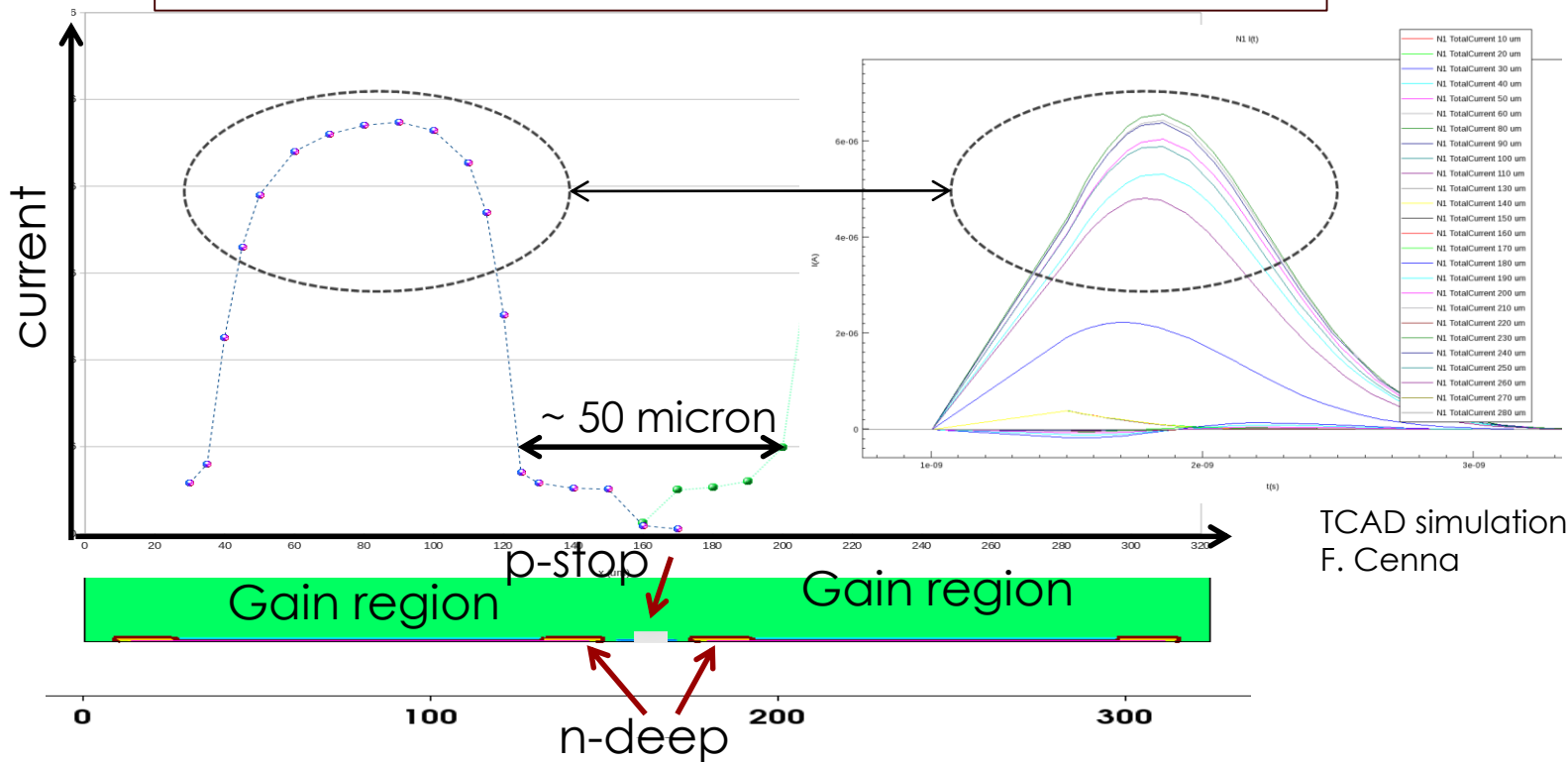
Detector occupancy per mm² at pile-up = 50

6 x 12 mm coverage,
to have 32 ch per plane



Lateral collector ring and sensor fill factor

No multiplication for particles hitting in between pads



Very important: **need n-deep well** at the end of each pad to prevent particles hitting in between pads from reaching the gain region.

Dead region: ~ 50 micron along each internal pad border = 5 mm²
Active area: 67/72 = 93% per sensor.

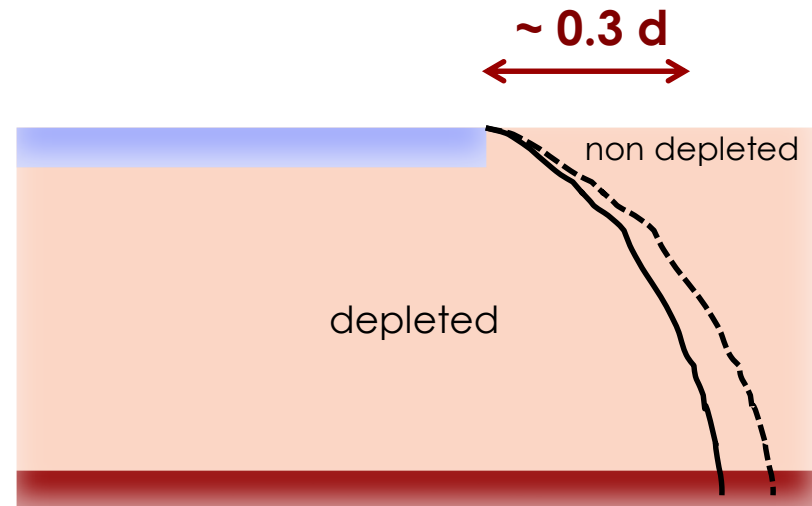
Sensor thickness and slim edge

Rule: when the depletion volume reaches the edge, you have electrical breakdown.

It's customary to assume that the field extends on the side by $\sim 1/3$ of the thickness.

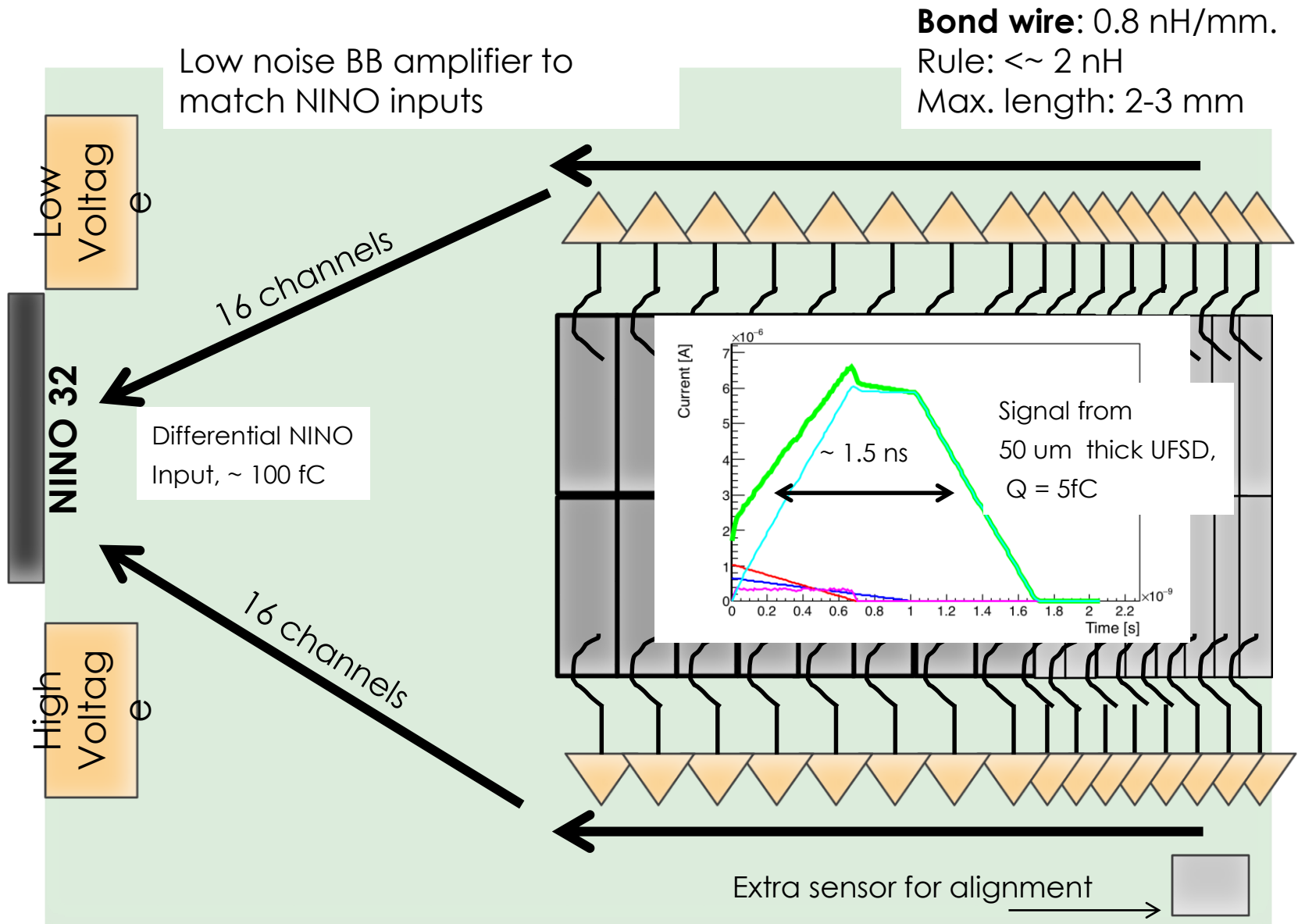
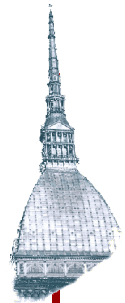
edge = $k \cdot$ thickness

- $k = 1$ very safe
- $k = 0.5$ quite safe
- $K = 0.3$ limit



By construction, thin detectors (~ 50 micron) have therefore slim edge

PPS proposed read-out card



Next steps

Done:

Testbeam in July with 300 micron thick UFSD sensors. Preliminary analysis indicates a time resolution of ~ 85 ps for a gain ~ 20 , and ~ 145 ps for a gain ~ 10 .

We finalized the 50 and 100 micron thick sensor design, and submit the production at CNM. Turn around time ~ 3 -4 months.

→ Foreseen time resolution ~ 40 ps

To be done:

- Develop the pre-amplifier chain, to be compatible with the NINO inputs. Need to be rad-hard. → Torino, Pilsen, Santa Cruz...?? ~ 6 month
- Evaluate the heating requirements
- Study the NINO behavior for very short pulses (Jose might help in this topic). Hopefully it works....
- Define the services needed in the tunnel: Low voltage, High voltage, cooling

Conclusions

Simulation shows a time resolution of ~ 40 ps for 4-6 pF sensors with gain ~ 15 .

We have developed a sensor design with minima dead area, short bond-wires and the possibility of 100% coverage. Ready by \sim winter 2015.

We are working towards a pre-amplifier design compatible with the NINO+HPTDC read-out chain.

→ Need to evaluate the NINO chip with UFSD sensors. Does it work?